Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	6328	(electroly\$10 or electrodeposit\$10 or electrochem\$10 or electroplat\$10) near3 (tin or Sn)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/12/07 13:32
L2	285	I1 and (complexing near3 agent\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/12/07 13:32
L3	173	I2 and (wetting or surfactant\$3 or (surface near3 active))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON.	2005/12/07 13:32
L4	82	l3 and (bi or bismuth)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/12/07 13:39
L5	22	l4 and ((conducting near3 salt\$3) or (anode\$2dissolving near3 agent\$3) or anti\$2oxidant\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	AND	ON	2005/12/07 13:40